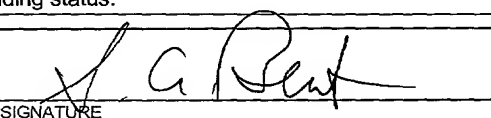


JC05 Rec'd PCT/PTO 1 4 JAN 2002

FORM PTO-1390 (Modified) (REV 5-93)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTORNEY'S DOCKET NUMBER 060953-0131
TRANSMITTAL LETTER TO THE UNITED STATES DESIGNATED/ELECTED OFFICE (DO/EO/US) CONCERNING A FILING UNDER 35 U.S.C. 371				
				U.S. APPLICATION NO. (if known, see 37 C.F.R. 1.5) Unassigned 10/030910
INTERNATIONAL APPLICATION NO. PCT/DE00/01833	INTERNATIONAL FILING DATE 05/31/2000	PRIORITY DATE CLAIMED 07/13/1999		
TITLE OF INVENTION ORGANICALLY MODIFIED SILICIC ACID POLYCONDENSATES, PRODUCTION AND USE THEREOF				
APPLICANT(S) FOR DO/EO/US Christof ROSCHER and Ralf BUESTRICH				
Applicant herewith submits to the United States Designated/Elected Office (DO/EO/US) the following items and other information:				
1.	<input checked="" type="checkbox"/>	This is a FIRST submission of items concerning a filing under 35 U.S.C. 371.		
2.	<input type="checkbox"/>	This is a SECOND or SUBSEQUENT submission of items concerning a filing under 35 U.S.C. 371.		
3.	<input type="checkbox"/>	This express request to begin national examination procedures (35 U.S.C. 371(f)) at any time rather than delay examination until the expiration of the applicable time limit set in 35 U.S.C. 371(b) and PCT Articles 22 and 39(1).		
4.	<input checked="" type="checkbox"/>	A proper Demand for International Preliminary Examination was made by the 19 th month from the earliest claimed priority date.		
5.	<input checked="" type="checkbox"/>	A copy of the International Application as filed (35 U.S.C. 371(c)(2)) <input type="checkbox"/> is transmitted herewith (required only if not transmitted by the International Bureau). <input checked="" type="checkbox"/> has been transmitted by the International Bureau. <input type="checkbox"/> is not required, as the application was filed in the United States Receiving Office (RO/US)		
6.	<input checked="" type="checkbox"/>	A translation of the International Application into English (35 U.S.C. 371(c)(2)).		
7.	<input checked="" type="checkbox"/>	Amendments to the claims of the International Application under PCT Article 19 (35 U.S.C. 371(c)(3)) <input type="checkbox"/> are transmitted herewith (required only if not transmitted by the International Bureau). <input checked="" type="checkbox"/> have been transmitted by the International Bureau. <input type="checkbox"/> have not been made; however, the time limit for making such amendments has NOT expired. <input checked="" type="checkbox"/> have not been made and will not be made.		
8.	<input type="checkbox"/>	A translation of the amendments to the claims under PCT Article 19 (35 U.S.C. 371(c)(3)).		
9.	<input type="checkbox"/>	An oath or declaration of the inventor(s) (35 U.S.C. 371(c)(4)).		
10.	<input type="checkbox"/>	A translation of the annexes to the International Preliminary Examination Report under PCT Article 36 (35 U.S.C. 371(c)(5)).		
11.	<input type="checkbox"/>	Applicant claims small entity status under 37 CFR 1.27.		
Items 12. to 17. below concern other document(s) or information included:				
12.	<input type="checkbox"/>	An Information Disclosure Statement under 37 CFR 1.97 and 1.98.		
13.	<input type="checkbox"/>	An assignment document for recording. A separate cover sheet in compliance with 37 CFR 3.28 and 3.31 is included.		
14.	<input checked="" type="checkbox"/>	A FIRST preliminary amendment. <input type="checkbox"/> A SECOND or SUBSEQUENT preliminary amendment.		
15.	<input type="checkbox"/>	A substitute specification.		
16.	<input type="checkbox"/>	A change of power of attorney and/or address letter.		
17.	<input type="checkbox"/>	Other items or information:		

U.S. APPLICATION NO. (If known, see 37 C.F.R. 1.50) Unassigned 10/030910		INTERNATIONAL APPLICATION NO. PCT/DE00/01833		ATTORNEY'S DOCKET NUMBER 060953-0131	
18. <input checked="" type="checkbox"/> The following fees are submitted:				CALCULATIONS	
Basic National Fee (37 CFR 1.492(a)(1)-(5): Search Report has been prepared by the EPO or JPO.....\$890.00					
International preliminary examination fee paid to USPTO (37 CFR 1.482).....\$710.00					
No international preliminary examination fee paid to USPTO (37 CFR 1.482) but international search fee paid to USPTO (37 CFR 1.445(a)(2))\$740.00					
Neither international preliminary examination fee (37 CFR 1.482) nor International search fee (37 CFR 1.445(a)(2)) paid to USPTO \$1,040.00					
International preliminary examination fee paid to USPTO (37 CFR 1.482) and all claims satisfied provisions of PCT Article 33(2)-(4)\$100.00					
ENTER APPROPRIATE BASIC FEE AMOUNT =				\$890.00	
Surcharge of \$130.00 for furnishing the oath or declaration later than 20 Months from the earliest claimed priority date (37 CFR 1.492(e))					
Claims	Number Filed	Included in Basic Fee	Extra Claims	Rate	
Total Claims	19	- 20	= 0	\$18.00	
Independent Claims	2	- 3	= 0	\$84.00	
Multiple dependent claim(s) (if applicable)				\$280.00	
TOTAL OF ABOVE CALCULATIONS =				\$890.00	
Reduction by 1/2 for filing by small entity, if applicable.				\$0.00	
SUBTOTAL =				\$890.00	
Processing fee of \$130.00 for furnishing English translation later the 20 months from the earliest claimed priority date (37 CFR 1.492(f)).				+	
TOTAL NATIONAL FEE =				\$890.00	
Fee for recording the enclosed assignment (37 CFR 1.21(h)). The assignment must be accompanied by an appropriate cover sheet (37 CFR 3.28, 3.31). \$40.00 per property +					
TOTAL FEES ENCLOSED =				\$890.00	
				Amount to be:	
				refunded \$	
				charged \$	
<p>a. <input checked="" type="checkbox"/> A check in the amount of \$890.00 to cover the above fees is enclosed.</p> <p>b. <input type="checkbox"/> Please charge my Deposit Account No. <u>19-0741</u> in the amount of \$890.00 to the above fees. A duplicate copy of this sheet is enclosed.</p> <p>c. <input checked="" type="checkbox"/> The Commissioner is hereby authorized to charge any additional fees which may be required, or credit any overpayment to Deposit Account No. <u>19-0741</u>. A duplicate copy of this sheet is enclosed.</p>					
<p>NOTE: Where an appropriate time limit under 37 CFR 1.494 or 1.495 has not been met, a petition to revive (37 CFR 1.137(a) or (b)) must be filed and granted to restore the application to pending status.</p>					
<p>SEND ALL CORRESPONDENCE TO:</p> <p>Foley & Lardner Washington Harbour 3000 K Street, N.W., Suite 500 Washington, D.C. 20007-5143</p>					
<p style="text-align: right;">  SIGNATURE NAME <u>STEPHEN A. BENT</u> REGISTRATION NUMBER <u>29,768</u> </p>					

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Christof ROSCHER *et al.*
Title: ORGANICALLY MODIFIED SILICIC
ACID POLYCONDENSATES,
PRODUCTION AND USE THEREOF
Appl. No.: Unassigned
Filing Date: Concurrently Herewith
Examiner: Unassigned
Art Unit: Unassigned

PRELIMINARY AMENDMENT

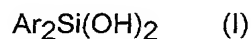
Commissioner for Patents
Box PATENT APPLICATION
Washington, D.C. 20231

Sir:

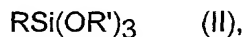
Prior to examination of the present Application, Applicant respectfully requests that the application be amended as follows:

In the Claims

1. (Amended) Organically modified, stable in storage, UV curable, NIR permeable silicic acid polycondensate which is photostructurable in layers having a thickness of 1 to 150 μm , obtainable by condensation of one or more organically modified silanediols of the general formula I and/or precondensates derived therefrom



with one or more organically modified silanes of the general formula II



wherein condensation occurs without the addition of water,

wherein the molar ratio of the compounds I and II in relation to the monomers is 1 : 1,

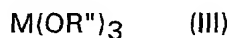
wherein up to 90 mole percent of said compound II can be replaced by one or more co-condensable compounds of boron, aluminum, silicon, germanium, titanium and zirconium, and wherein the radicals are identical or different and have the following meaning:

Ar = a radical having 6 to 20 carbon atoms and at least one aromatic group,

R = an organic radical having 2 to 15 carbon atoms and at least one epoxy group and/or at least one C = C double bond,

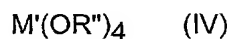
R' = methyl or ethyl.

2. (Amended) Silicic acid polycondensate according to claim 1, wherein up to 90 mole percent of said compound of the general formula II are replaced by one or more compounds of the general formula III,



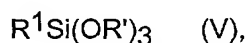
in which M means one of boron and aluminum, R'' represents an alkyl radical with 1 to 4 carbon atoms, and wherein the molar ratio of said replaced compound II in relation to said compound III is 3 : 2.

3. (Amended) Silicic acid polycondensate according to claim 1, wherein up to 90 mole percent of said compound of the general formula II are replaced by one or more compounds of the general formula IV



in which M' means silicon, germanium, titanium or zirconium, R'' represents an alkyl radical having 1 to 4 carbon atoms, and wherein the molar ratio of said replaced compound II in relation to said compound IV is 2 : 1.

4. (Amended) Silicic acid polycondensate according to claim 1, wherein up to 90 mole percent of said compound of the general formula II are replaced by one or more compounds of the general formula V, wherein the molar ratio of said replaced compound II in relation to compound V is 1 : 1,



and wherein the radicals are identical or different and have the following meaning:

$R' =$ methyl or ethyl,

$R^1 =$ $CF_3-(CF_2)_n-C_2H_4-$, with $n = 0$ to 7 ,

$R^2HN-(CH_2)_3-$, with $R^2 = H, CH_3, C_2H_5$ or $C_2H_4-NHR^2$,

$H_2N-C_2H_4-NH-CH_2-C_6H_4-C_2H_4-$,

substituted and unsubstituted alkyl having 1 to 8 carbon atoms,

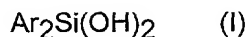
substituted and unsubstituted phenyl, tolyl and naphthyl.

5. (Amended) Silicic acid polycondensate according to claim 1, wherein up to 80 mole percent of said compound II are replaced by more than one compound selected from the group consisting of more than one compound of general formula III, more than one compound of general formula IV, more than one compound of general formula V, compounds of general formula III and IV, compounds of general formula III and V, compounds of general formula IV and V and compounds of general formula III and IV and V.

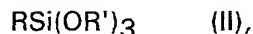
6. (Amended) Silicic acid polycondensate according to claim 1, obtainable by using a condensation catalyst which is triethylamine, NH_4F or an alkaline earth hydroxide.

7. (Amended) Silicic acid polycondensate according to claim 1, obtainable by compounds selected from those of the general formula III, IV (with M' being Ti or Zr) or V (with R^1 being $R^2HN-(CH_2)_3-$ or $H_2N-C_2H_4-NH-CH_2-C_6H_4-C_2H_4-$) acting as condensation catalysts.

8. (Amended) Silicic acid polycondensate according to claim 1, wherein said radical Ar of the general formula I means a substituted aromatic radical.
9. (Amended) Silicic acid polycondensate according to claim 8, wherein said radical Ar of the general formula I means phenyl, naphthyl or styryl.
10. (Amended) Silicic acid polycondensate according to claim 1, wherein said radical R of the general formula II contains functional groups.
11. (Amended) Silicic acid polycondensate according to claim 1, wherein said radical R¹ of the general formula V contains SH groups and/or NR^{*}₂ groups, with R^{*} being hydrogen or alkyl.
12. (Amended) Silicic acid polycondensate according to claim 1, wherein said radical R of the general formula II contains at least one acryl and/or methacryl group.
13. (Amended) Silicic acid polycondensate according to claim 1, obtainable by adding polysiloxanes to the reaction medium, said polysiloxanes having been obtained by reacting organically modified silanediols of the general formula I with organically modified silanes of the general formula II.
14. (Amended) A stable in storage, UV curable, NIR permeable material that is photostructurable in layers of a thickness of 1 to 150 μm, wherein said material comprises a silicic acid polycondensate according to claim 1.
15. (Amended) A material according to claim 14, wherein said material is a negative resist.
17. (New) Silicic acid polycondensate, obtainable by condensation of one or more organically modified silanediols of the general formula I and/or precondensates derived therefrom



with one or more organically modified silanes of the general formula II



wherein condensation occurs without the addition of water,

wherein the molar ratio of the compounds I and II in relation to the monomers is 1 : 1, wherein up to 90 mole percent of said compound II can be replaced by one or more co-condensable compounds of boron, aluminum, silicon, germanium, titanium and zirconium, and wherein the radicals are identical or different and have the following meaning:

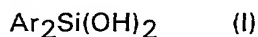
Ar = a radical having 6 to 20 carbon atoms and at least one aromatic group,

R = an organic radical having 2 to 15 carbon atoms and at least one epoxy group and/or at least one C=C double bond,

R' = methyl or ethyl.

18. (New) A material that is photostructurable in layers of a thickness of 1 to 150 μm , wherein said material comprises an organically modified silicic acid polycondensate according to claim 17.

19. (New) Method for producing the silicic acid polycondensates according to claim 17 by condensing one or more organically modified silanediols of the general formula I and/or precondensates derived therefrom



with one or more organically modified silanes of the general formula II

RSi(OR')₃ (II)

in the presence of a base,

wherein condensation occurs without the addition of water,

wherein the molar ratio of the compounds I and II in relation to the monomers is 1 : 1,

wherein up to 90 mole percent of said compound II can be replaced by one or more co-condensable compounds of boron, aluminum, silicon, germanium, titanium and zirconium,

and wherein the radicals are identical or different and have the following meaning:

Ar = a radical having 6 to 20 carbon atoms and at least one aromatic group,

R = an organic radical having 2 to 15 carbon atoms and at least one epoxy group and/or at least one C=C double bond,

R' = methyl or ethyl.

REMARKS

Upon entry of the claim revisions set forth above, claims 1-19 will be pending in this application. Applicants respectfully request that the PTO make those revisions prior to examination of the present application.

Respectfully submitted,

Date 14 January 2002

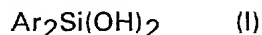
By S. A. Bent

FOLEY & LARDNER
Washington Harbour
3000 K Street, N.W., Suite 500
Washington, D.C. 20007-5143
Telephone: (202) 672-5404
Facsimile: (202) 672-5399

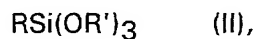
Stephen A. Bent
Attorney for Applicant
Registration No. 29,768

Mark-up Version of Amended Claims

1. (Amended) Organically modified, stable in storage, UV curable, NIR permeable silicic acid polycondensate which is photostructurable in layers having a thickness of 1 to 150 μm , obtainable by condensation of one or more organically modified silanediols of the general formula I and/or precondensates derived therefrom



with one or more organically modified silanes of the general formula II



wherein condensation occurs without the addition of water,

wherein the molar ratio of the compounds I and II in relation to the monomers is 1 : 1,

wherein up to 90 mole percent of said compound II can be replaced by one or more co-condensable compounds of boron, aluminum, silicon, germanium, titanium and zirconium,

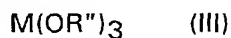
and wherein the radicals are identical or different and have the following meaning:

Ar = a radical having 6 to 20 carbon atoms and at least one aromatic group,

R = an organic radical having 2 to 15 carbon atoms and at least one epoxy group and/or at least one C=C double bond,

R' = methyl or ethyl.

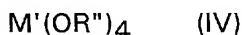
2. (Amended) Silicic acid polycondensate according to claim 1, [characterized in that] wherein up to 90 mole percent of said compound of the general formula II are replaced by one or more compounds of the general formula III,



20025010160001

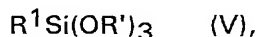
in which M means one of boron and aluminum, R" represents an alkyl radical with 1 to 4 carbon atoms, and wherein the molar ratio of said replaced compound II in relation to said compound III is 3 : 2.

3. (Amended) Silicic acid polycondensate according to [one of] claim[s] 1 [and 2], [characterized in that] wherein up to 90 mole percent of said compound of the general formula II are replaced by one or more compounds of the general formula IV



in which M' means silicon, germanium, titanium or zirconium, R" represents an alkyl radical having 1 to 4 carbon atoms, and wherein the molar ratio of said replaced compound II in relation to said compound IV is 2 : 1.

4. (Amended) Silicic acid polycondensate according to [one or more of] claim[s] 1 [to 3], [characterized in that] wherein up to 90 mole percent of said compound of the general formula II are replaced by one or more compounds of the general formula V, wherein the molar ratio of said replaced compound II in relation to compound V is 1 : 1,



and wherein the radicals are identical or different and have the following meaning:

R' = methyl or ethyl,

R¹ = CF₃-(CF₂)_n-C₂H₄-, with n = 0 to 7,

R²HN-(CH₂)₃-, with R² = H, CH₃, C₂H₅ or C₂H₄-NHR²,

H₂N-C₂H₄-NH-CH₂-C₆H₄-C₂H₄-,

substituted and unsubstituted alkyl having 1 to 8 carbon atoms,

substituted and unsubstituted phenyl, tolyl and naphthyl.

5. (Amended) Silicic acid polycondensate according to [one or more of] claim[s] 1 [to 4], [characterized in that] wherein up to 80 mole percent of said compound II are

replaced by [one or] more than one compound[s] selected from the group consisting of more than one compound of general formula III, more than one compound of general formula IV, more than one compound of general formula V, compounds of general formulae III and IV, compounds of general formulae III and V, compounds of general formulae IV and V and compounds of general formulae III, IV and V [of the general formula III and/or IV and/or V].

6. (Amended) Silicic acid polycondensate according to [one or more of] claim[s] 1 [to 5], obtainable by using a condensation catalyst which is triethylamine, NH_4F or an alkaline earth hydroxide.

7. (Amended) Silicic acid polycondensate according to [one or more of] claim[s] 1 [to 6], obtainable by compounds selected from those of the general formula III, IV (with M' being Ti or Zr) [or] and V (with R^1 being $\text{R}^2\text{HN}-(\text{CH}_2)_3-$ or $\text{H}_2\text{N}-\text{C}_2\text{H}_4-\text{NH}_2-\text{CH}_2-\text{C}_6\text{H}_4-\text{C}_2\text{H}_4-$) acting as condensation catalysts.

8. (Amended) Silicic acid polycondensate according to [one or more of] claim[s] 1 [to 7], [characterized in that] wherein said radical Ar of the general formula I means a substituted aromatic radical.

9. (Amended) Silicic acid polycondensate according to claim 8, [characterized in that] wherein said radical Ar of the general formula I means phenyl, naphthyl or styryl.

10. (Amended) Silicic acid polycondensate according to [one or more of] claim[s] 1 [to 9], [characterized in that] wherein said radical R of the general formula II contains functional groups.

11. (Amended) Silicic acid polycondensate according to [one or more of] claim[s] 1 [to 10] [characterized in that] wherein said radical R^1 of the general formula V contains SH groups and/or NR^*_2 groups, with R^* being hydrogen or alkyl.

12. (Amended) Silicic acid polycondensate according to [one or more of] claim[s] 1 [to 11], [characterized in that] wherein said radical R of the general formula II contains at least one acryl and/or methacryl group.

13. (Amended) Silicic acid polycondensate according to [one or more of] claim[s] 1 [to 12], obtainable by adding polysiloxanes to the reaction medium, said polysiloxanes having been obtained by reacting organically modified silanediols of the general formula I with organically modified silanes of the general formula II.

14. (Amended) [Use of the organically modified silicic acid polycondensates according to one or more of claims 1 to 13 as] A stable in storage, UV curable, NIR permeable materials [which are] that is photostructurable in layers of a thickness of 1 to 150 μm , wherein said material comprises a silicic acid polycondensate according to claim 1.

15. (Amended) [Use] A material according to claim 14, wherein said material is [as] a negative resist.

* * *

Organically modified, stable in storage, UV curable, NIR permeable silicic acid polycondensates which are photostructurable in layers of a thickness of 1 to 150 μm , production and use thereof

5 The invention relates to organically modified, stable in storage, UV curable, NIR permeable silicic acid polycondensates which are photostructurable in layers having a thickness of 1 to 150 μm , as well as to the production and use thereof.

10 Organically modified silicic acid polycondensates are widely used e. g. as coatings for a very wide range of substrates or in the production of moldings. In contrast to merely organic polymers, organically modified silicic acid polycondensates have numerous advantageous properties, as for example a higher temperature resistance and dimensional stability under heat, a better adhesion, etc..

15 Organically modified silicic acid polycondensates according to prior art are obtained by aqueous sol-gel-synthesis, i. e. by hydrolytic condensation reactions, and therefore they comprise Si-OH groups. A disadvantage of said organically modified silicic acid polycondensates containing Si-OH groups is the bad reproducibility of their synthesis and the insufficient stability in storage. The Si-OH groups contained in the system react slowly by self-condensation, which results in a viscosity increase of the system.

20 A further disadvantage of said systems is an increased loss and the formation of cracks upon their application. Systems containing Si-OH groups release water and alcohol under shrinkage when thermally hardened. The shrinkage and the emission of volatile components leads to a formation of cracks, particularly in case of higher layer thickness.

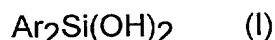
25 Said inorganic postcondensation is very disadvantageous, particularly for structurable materials. Prior to structuring by organic polymerization, the inorganic oligomer formation should already be terminated, the mobility of the Si-OH groups after said organic polymerization being restricted. If the inorganic oligomer formation is not terminated, SiOH groups remain in the system and lead to an increased absorption of water.

30 A further disadvantage of said systems is their high absorption by said Si-OH groups in the NIR range, particularly at a wave length of 1550 nm which is of great importance in optical data processing.

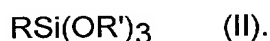
10050910-000002

The object of the present invention is therefore to provide materials for coatings and for the production of moldings, which materials are stable in storage, UV curable, NIR permeable and which are photostructurable in layers of even high thickness. The intention is that said materials should adhere to a very wide range of substrates and be applicable by usual methods.

This object is achieved by providing organically modified silicic acid polycondensates which are obtainable by condensation of one or more organically modified silanediols of the general formula I



with one or more organically modified silanes of the general formula II



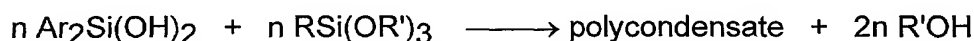
Instead of the monomer compounds of the general formula I, precondensates derived therefrom or mixtures of monomers and precondensates can also be used for producing silicic acid polycondensates according to the invention. The molar ratio of the compounds I and II in relation to the monomers is 1 : 1.

Up to 90 mole percent of the compound of general formula II can be replaced by one or more co-condensable compounds of boron, aluminum, silicon, germanium, titanium and zirconium. If compounds of the general formula II are replaced by said co-condensable compounds, the molar ratio of the compounds I and II obviously changes. When replacing compounds of the general formula II by co-condensable compounds it is to be taken care that the quantity of the condensable groups of compound II be replaced by an equivalent quantity of co-condensable groups. It has to be considered that in the compound of general formula II, only two out of three alkoxy groups are capable of condensation.

The radicals of the general formulas I and II are identical or different and have the following meaning:

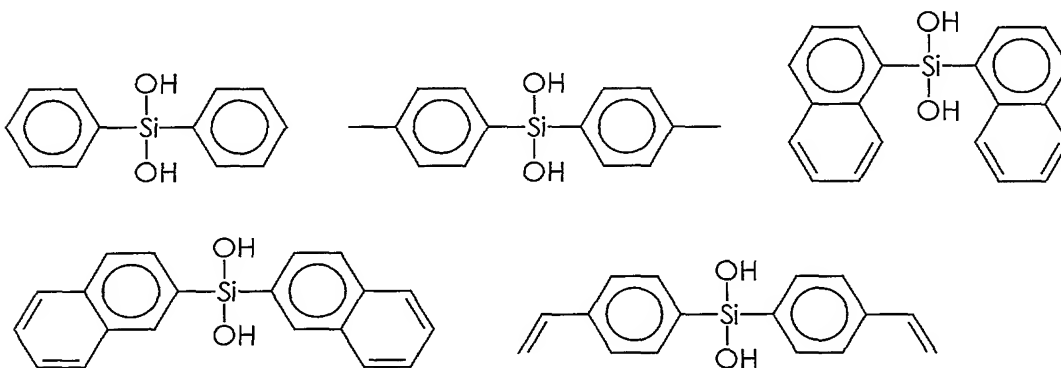
- Ar = a radical having 6 to 20 carbon atoms and at least one aromatic group,
R = an organic radical having 2 to 15 carbon atoms and at least one epoxy group and/or at least one C=C double bond,
R' = methyl or ethyl.

Silanes of the general formula II are condensable with silanediols of the general formula I via radicals OR', whereby separation of methanol or ethanol, respectively, occurs. In the course of said condensation, an inorganic network having Si-O-Si bridges is built up. The free valences of the silicon atoms are saturated by Ar, R and R'O radicals. The general reaction scheme of the condensation looks as follows:



Silanes of the general formula II can further be polymerized via the epoxy groups and over the C=C double bonds of the radicals R, respectively. An organic network is built up by polymerizing said radicals R.

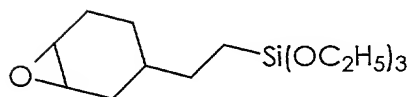
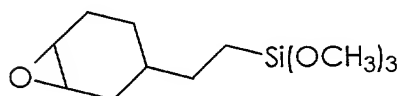
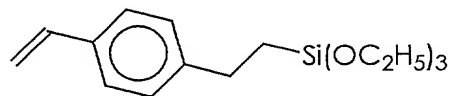
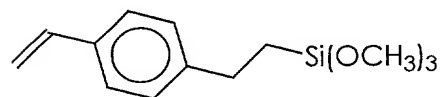
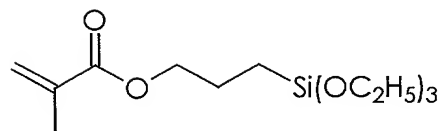
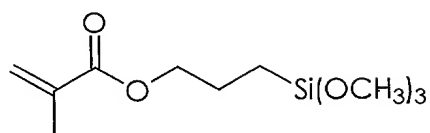
In preferred embodiments of the silicic acid polycondensates according to the invention, the radical Ar of the general formula I means a substituted or unsubstituted aromatic radical. It is particularly preferred that Ar means phenyl, tolyl, styryl or naphthyl. Concrete examples of compounds of the general formula are



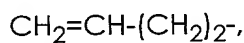
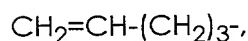
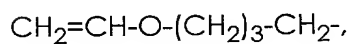
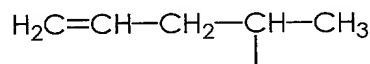
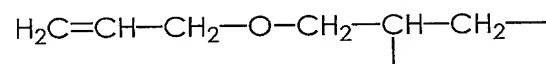
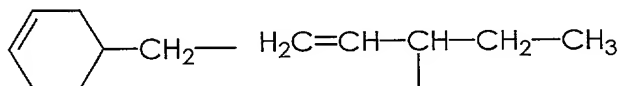
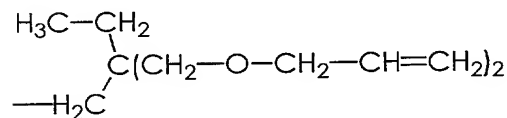
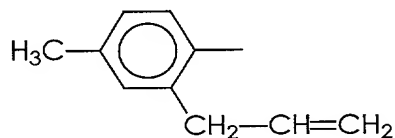
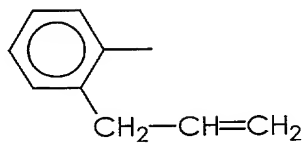
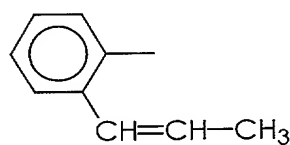
Compounds of the general formula I can be purchased or produced according to methods as described e. g. in "Chemie und Technologie der Silicone" (Walter Noll, Verlag Chemie, Weinheim/Bergstraße, 1986).

Without limitation as to generality, concrete examples of compounds of the general formula II are

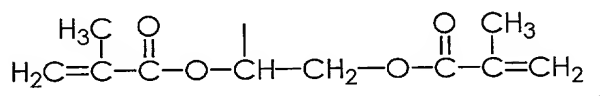
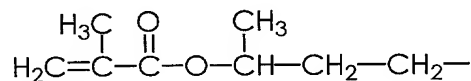
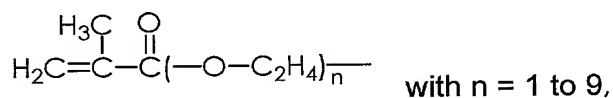


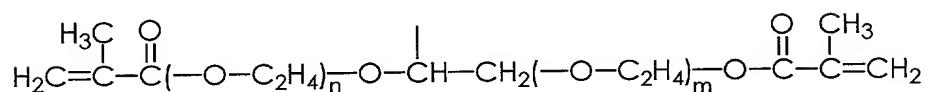
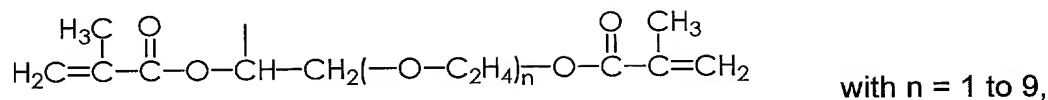
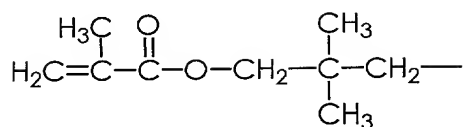


Further concrete embodiments of the radicals R look e. g. as follows:

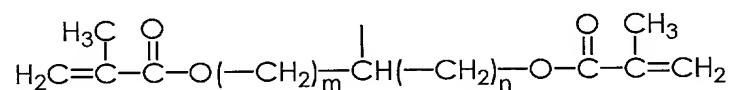
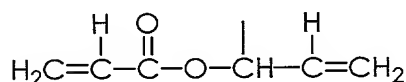
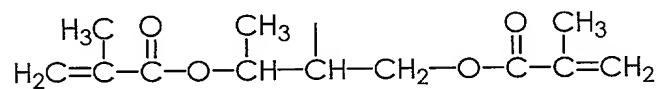
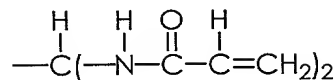
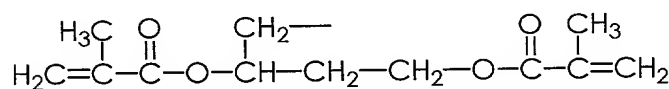
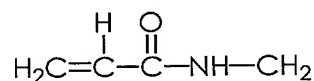
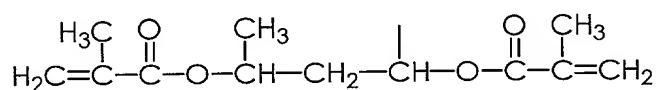
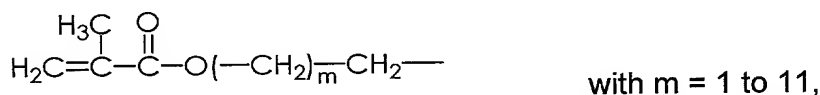


In preferred embodiments of the polycondensates according to the invention, the radical R contains one or more acryl and/or methacryl groups in compounds of the general formula II. Without limitation as to generality, concrete embodiments of such radicals R are

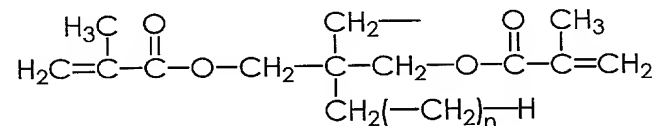




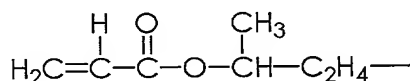
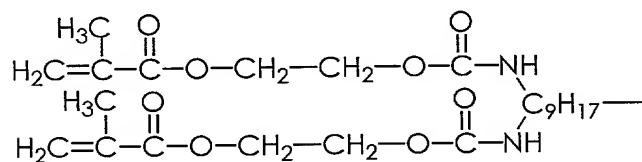
with m and $n = 1$ to 6 and $m + n = 2$ to 8 ,

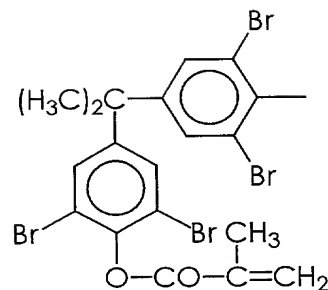
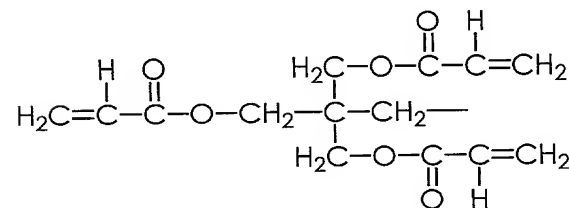
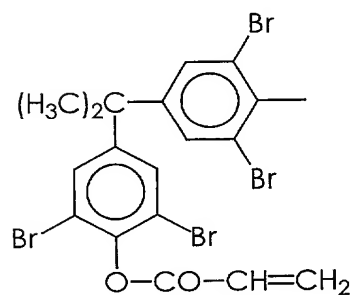
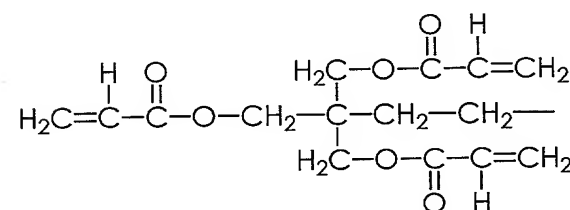
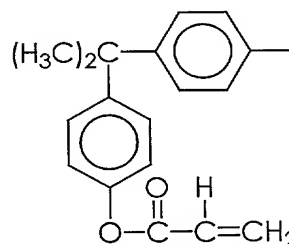
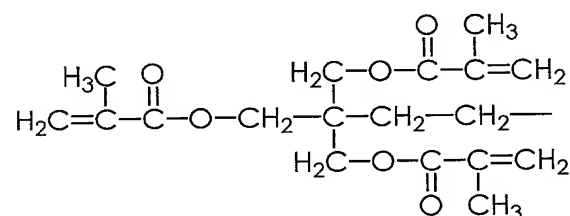
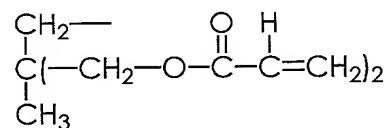
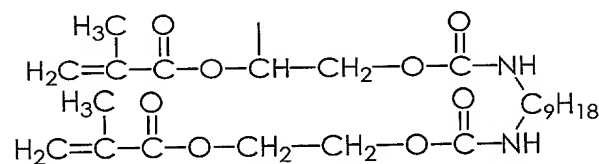
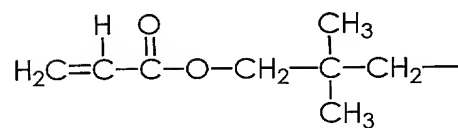
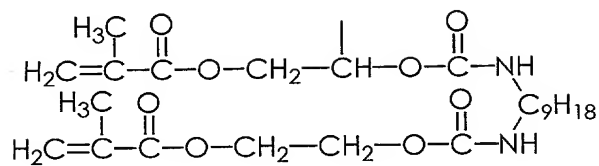


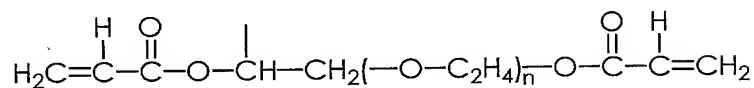
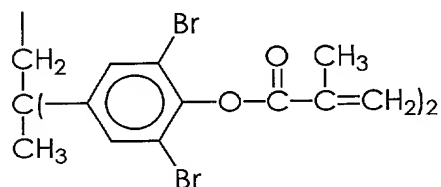
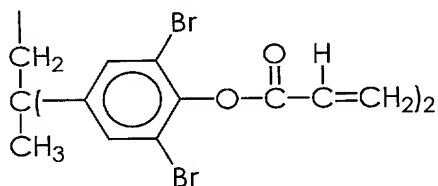
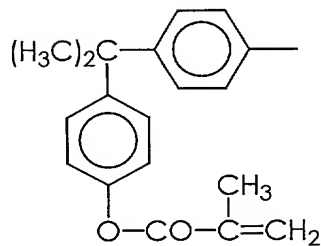
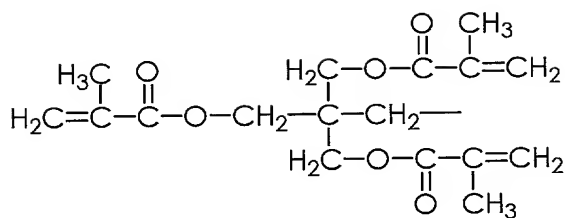
with n , m and $m+n = 0$ to 11 ,



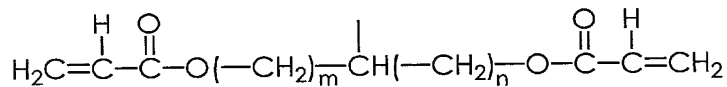
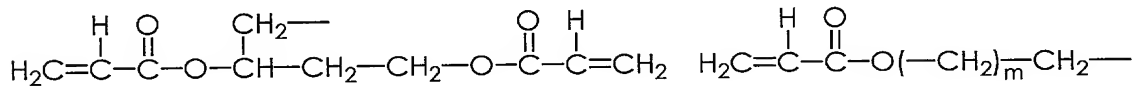
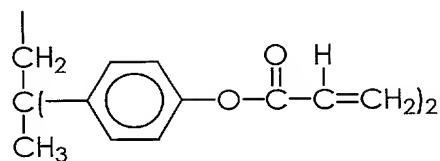
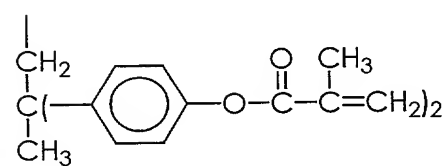
with $n = 0$ and 1 ,



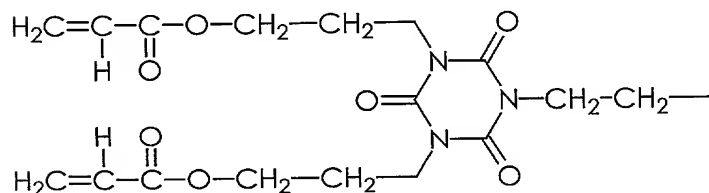
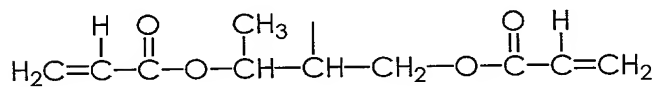


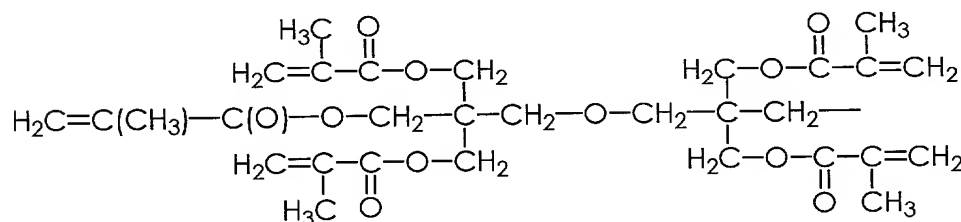
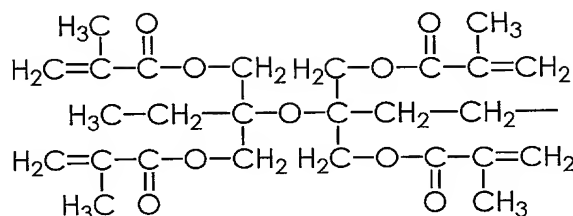
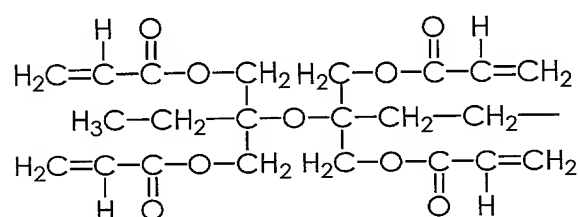
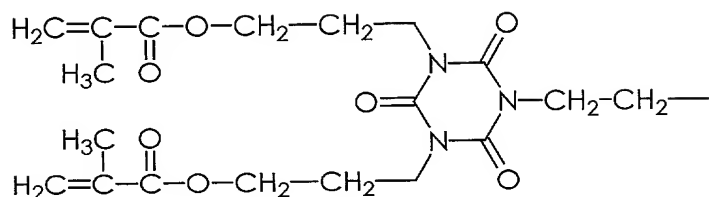


with n = 0 to 9,



with n, m and n+m = 0 to 11,





Compounds of the general formula II can be purchased or produced according to methods, as described e. g. in "Chemie und Technologie der Silicone" (Walter Noll, Verlag Chemie, Weinheim/Bergstrasse, 1986).

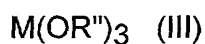
For building up the inorganic network and for producing the silicic acid polycondensates according to the invention, the compounds of the general formula I and II are condensed. Polycondensation is preferably effected according to the sol-gel-method and at temperatures between 20 and 100°C, preferably between 50 and 100°C, or at the boiling point of the lowest boiling component. Particularly preferred is a condensation at the boiling temperature of the methanol. After condensation, devolatilization is effected by usual methods, e. g. by heating and/or negative pressure.

For initializing or accelerating condensation, Lewis or Brönstedt bases can be used. Examples thereof are amines, as e. g. N-methylimidazole or benzyldimethylamine. In preferred embodiments, triethylamine, ammonium fluoride, or one or more alkaline earth hydroxides is/are used as bases. It is particularly preferred to use barium hydroxide as alkaline earth hydroxide. If insoluble bases are used in the reaction medium, such as e. g. alkaline earth hydroxides, it is recommended to separate them, e. g. by filtration, from the resulting mixture after the condensation has terminated. Further, chelated or

non-chelated aluminum or zirconium alkoxides can be used for condensation instead of the aforementioned bases.

For producing the polycondensates according to the invention, up to 90 mole percent of the compound of the general formula II can be replaced by one or more co-condensable compounds of boron, aluminum, silicon, germanium, titanium and zirconium.

In a further embodiment of the silicic acid polycondensates according to the invention, compounds of the general formula II are replaced by one or more co-condensable compounds of the general formula III.



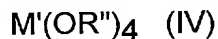
The radicals R'' are identical or different, M means boron or aluminum and R'' represents an alkyl radical having 1 to 4 carbon atoms. In the general formula III, all three alkoxy radicals are co-condensable with compounds of the general formula I, so that a replacement of compounds of the general formula II by compounds of the general formula III is effected at a molar ratio of 3 : 2. This means that three molecules, respectively, of compound II are to be replaced by two molecules of compound III.

Concrete examples of compounds of the general formula III are $Al(OCH_3)_3$, $Al(OC_2H_5)_3$, $Al(O-n-C_3H_7)_3$, $Al(O-i-C_3H_7)_3$, $Al(O-n-C_4H_9)_3$, $Al(O-i-C_4H_9)_3$, $Al(O-s-C_4H_9)_3$, $B(O-n-C_4H_9)_3$, $B(O-t-C_4H_9)_3$, $B(O-n-C_3H_7)_3$, $B(O-i-C_3H_7)_3$, $B(OCH_3)_3$ and $B(OC_2H_5)_3$.

When replacing compounds of the general formula II partly by the aforementioned aluminum and boron compounds, the addition of a base for effecting condensation is no longer required. The aforementioned aluminum and boron compounds act as condensation catalyst. A further advantage of said embodiment is that excess condensation catalyst does not have to be removed from the reaction medium after condensation has terminated, since no free condensation catalyst is present any more. It is completely incorporated in the inorganic network.

By incorporating aluminum and/or boron atoms into the inorganic network, the hardness and the chemical resistance of the resulting polycondensate is increased.

In a further embodiment of the silicic acid polycondensates according to the invention, compounds of the general formula II are replaced by one or more co-condensable compounds of the general formula IV.



The radicals R'' are identical or different, M' means silicon, germanium, titanium or zirconium, and R'' represents an alkyl radical having 1 to 4 carbon atoms. In the general formula IV, all four alkoxy radicals are co-condensable with compounds of the general formula I, so that a replacement of compounds of the general formula II by compounds of the general formula IV is effected at a molar ratio of 2 : 1. This means that two molecules of compound II are replaced by one molecule of compound IV.

Concrete examples of compounds of the general formula IV are Si(OCH₃)₄, Si(OC₂H₅)₄, Si(O-n-C₃H₇)₄, Si(O-i-C₃H₇)₄, Si(O-n-C₄H₉)₄, Si(O-i-C₄H₉)₄, Si(O-s-C₄H₉)₄, Ge(OCH₃)₄, Ge(OC₂H₅)₄, Ge(O-n-C₃H₇)₄, Ge(O-i-C₃H₇)₄, Ge(O-n-C₄H₉)₄, Ge(O-i-C₄H₉)₄, Ge(O-s-C₄H₉)₄, Ti(OCH₃)₄, Ti(OC₂H₅)₄, Ti(O-n-C₃H₇)₄, Ti(O-i-C₃H₇)₄, Ti(O-n-C₄H₉)₄, Ti(O-i-C₄H₉)₄, Ti(O-s-C₄H₉)₄, Zr(OCH₃)₄, Zr(OC₂H₅)₄, Zr(O-n-C₃H₇)₄, Zr(O-i-C₃H₇)₄, Zr(O-n-C₄H₉)₄, Zr(O-i-C₄H₉)₄ and Zr(O-s-C₄H₉)₄.

When replacing compounds of the general formula II partly by the above mentioned compounds of titanium and zirconium, said titanium and zirconium compounds also cause condensation, the addition of a catalyst, e. g. of a base, not being required any more. Thus, the above mentioned titanium and zirconium compounds take over the function of a condensation catalyst. A further advantage of said embodiment is that after condensation is terminated, excess catalyst does not have to be removed from the reaction medium any more since it is completely incorporated in the inorganic network.

By incorporating germanium and/or titanium and/or zirconium atoms into the inorganic network, the hardness and the resistance to abrasion of the resulting polycondensate are increased on the one hand due to the higher inorganic network density. On the other hand, the refractive index of the resulting polycondensate is shifted to higher values. Therefore, by selectively incorporating said atoms in the inorganic network, the refractive index of the resulting material can selectively be adjusted. Therefore, said materials are excellently suited for use in optical components, since a selective adjustment of the refractive index, e. g. in the light transmission for coupling and decoupling, is absolutely required in said optical components.

In further embodiments of the silicic acid polycondensates according to the invention, up to 90 mole percent of the compounds of the general formula II are replaced by one or more compounds of the general formula V.

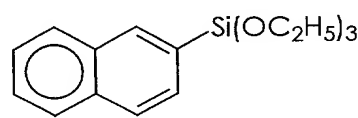
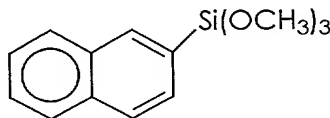
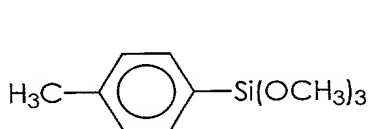
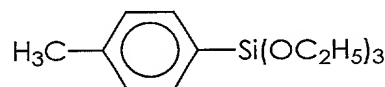
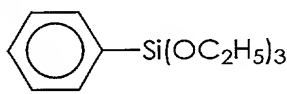
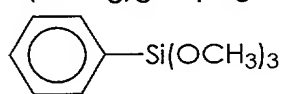


The radicals R' are identical or different and mean methyl or ethyl. The radical R¹ is an organic radical having the following meaning:

R¹ = CF₃-(CF₂)_n-C₂H₄-, with n = 0 to 7,
R²HN-(CH₂)₃-, with R² = H, CH₃, C₂H₅ or C₂H₄-NHR²,
H₂N-C₂H₄-NH-CH₂-C₆H₄-C₂H₄-,
substituted and unsubstituted alkyl having 1 to 8 carbon atoms,
substituted and unsubstituted phenyl, tolyl or naphthyl.

Compounds II are replaced by compounds of the general formula V at a molar ratio of 1 : 1. Concrete examples of compounds of the general formula V are

CF₃-C₂H₄-Si(OCH₃)₃, CF₃-CF₂-C₂H₄-Si(OCH₃)₃, CF₃-(CF₂)₂-C₂H₄-Si(OCH₃)₃,
CF₃-(CF₂)₃-C₂H₄-Si(OCH₃)₃, CF₃-(CF₂)₄-C₂H₄-Si(OCH₃)₃, CF₃-(CF₂)₅-C₂H₄-
Si(OCH₃)₃, CF₃-(CF₂)₆-C₂H₄-Si(OCH₃)₃, CF₃-(CF₂)₇-C₂H₄-Si(OCH₃)₃, CF₃-C₂H₄-
Si(OC₂H₅)₃, CF₃-CF₂-C₂H₄-Si(OC₂H₅)₃, CF₃-(CF₂)₂-C₂H₄-Si(OC₂H₅)₃, CF₃-
(CF₂)₃-C₂H₄-Si(OC₂H₅)₃, CF₃-(CF₂)₄-C₂H₄-Si(OC₂H₅)₃, CF₃-(CF₂)₅-C₂H₄-
Si(OC₂H₅)₃, H₃C-Si(OCH₃)₃, CF₃-(CF₂)₆-C₂H₄-Si(OC₂H₅)₃, CF₃-(CF₂)₇-C₂H₄-
Si(OC₂H₅)₃, H₃C-Si(OC₂H₅)₃, H₅C₂-Si(OCH₃)₃, H₅C₂-Si(OC₂H₅)₃, H₇C₃-
Si(OCH₃)₃, H₇C₃-Si(OC₂H₅)₃,



By replacing compounds of the general formula II by compounds of the general formula V, the refractive index and the optical attenuation of the polycondensates according to the invention can be adapted to the requirements of each respective application case. At 1310 nm and at 1550 nm, alkylated components for example cause a reduction of the refractive index simultaneously increasing attenuation. Probably, C-H-harmonic oscillations and combination vibrations of the polycondensate according to the invention are responsible for this. Arylated components cause an increase of the refractive index (e. g. at 1550 nm) without significantly increasing the attenuation of the

material according to the invention. Fluorinated components reduce both the refractive index and the attenuation of the polycondensates according to the invention.

Further concrete embodiments of compounds of the general formula V look as follows.

H₂N-(CH₂)₃-Si(OCH₃)₃, H₃C-NH-(CH₂)₃-Si(OCH₃)₃, H₅C₂-NH-(CH₂)₃-Si(OCH₃)₃,
H₂N-C₂H₄-NH-(CH₂)₃-Si(OCH₃)₃, H₃C-NH-C₂H₄-NH-(CH₂)₃-Si(OCH₃)₃, H₅C₂-NH-
C₂H₄-NH-(CH₂)₃-Si(OCH₃)₃, H₂N-(CH₂)₃-Si(OC₂H₅)₃, H₃C-NH-(CH₂)₃-Si(OC₂H₅)₃,
H₅C₂-NH-(CH₂)₃-Si(OC₂H₅)₃, H₂N-C₂H₄-NH-(CH₂)₃-Si(OC₂H₅)₃, H₃C-NH-C₂H₄-
NH-(CH₂)₃-Si(OC₂H₅)₃, H₅C₂-NH-C₂H₄-NH-(CH₂)₃-Si(OC₂H₅)₃, H₂N-C₂H₄-NH-
CH₂-C₆H₄-C₂H₄-Si(OCH₃)₃, H₂N-C₂H₄-NH-CH₂-C₆H₄-C₂H₄-Si(OC₂H₅)₃, H₂N-
(CH₂)₃-Si(OCH₃)₃, H₃C-N(CH₃)-(CH₂)₃-Si(OCH₃)₃, H₅C₂-N(CH₃)-(CH₂)₃-
Si(OCH₃)₃, H₂N-C₂H₄-N(CH₃)-(CH₂)₃-Si(OCH₃)₃, H₃C-N(CH₃)-C₂H₄-N(CH₃)-
(CH₂)₃-Si(OCH₃)₃, H₅C₂-N(CH₃)-C₂H₄-N(CH₃)-(CH₂)₃-Si(OCH₃)₃, H₂N-(CH₂)₃-
Si(OC₂H₅)₃, H₃C-N(CH₃)-(CH₂)₃-Si(OC₂H₅)₃, H₅C₂-N(CH₃)-(CH₂)₃-Si(OC₂H₅)₃,
H₂N-C₂H₄-N(CH₃)-(CH₂)₃-Si(OC₂H₅)₃, H₃C-N(CH₃)-C₂H₄-N(CH₃)-(CH₂)₃-
Si(OC₂H₅)₃, H₅C₂-N(CH₃)-C₂H₄-N(CH₃)-(CH₂)₃-Si(OC₂H₅)₃, H₂N-C₂H₄-N(CH₃)-
CH₂-C₆H₄-C₂H₄-Si(OCH₃)₃, H₂N-C₂H₄-N(CH₃)-CH₂-C₆H₄-C₂H₄-Si(OC₂H₅)₃, H₂N-
(CH₂)₃-Si(OCH₃)₃, H₃C-N(C₂H₅)-(CH₂)₃-Si(OCH₃)₃, H₅C₂-N(C₂H₅)-(CH₂)₃-
Si(OCH₃)₃, H₂N-C₂H₄-N(C₂H₅)-(CH₂)₃-Si(OCH₃)₃, H₃C-N(C₂H₅)-C₂H₄-N(C₂H₅)-
(CH₂)₃-Si(OCH₃)₃, H₅C₂-N(C₂H₅)-C₂H₄-N(C₂H₅)-(CH₂)₃-Si(OCH₃)₃, H₂N-(CH₂)₃-
Si(OC₂H₅)₃, H₃C-N(C₂H₅)-(CH₂)₃-Si(OC₂H₅)₃, H₅C₂-N(C₂H₅)-(CH₂)₃-Si(OC₂H₅)₃,
H₂N-C₂H₄-N(C₂H₅)-(CH₂)₃-Si(OC₂H₅)₃, H₃C-N(C₂H₅)-C₂H₄-N(C₂H₅)-(CH₂)₃-
Si(OC₂H₅)₃, H₅C₂-NH-C₂H₄-N(C₂H₅)-(CH₂)₃-Si(OC₂H₅)₃, H₂N-C₂H₄-N(C₂H₅)-
CH₂-C₆H₄-C₂H₄-Si(OCH₃)₃, H₂N-C₂H₄-N(C₂H₅)-CH₂-C₆H₄-C₂H₄-Si(OC₂H₅)₃.

When using said compounds in replacement of compounds of the general formula II, the great advantage is that they act as base and take over the function of the condensation catalyst. A further advantage is that excess base does not have to be removed from the reaction medium after condensation is terminated, since it is completely incorporated in the inorganic network.

In further embodiments of the silicic acid polycondensates according to the invention, the radical R¹ of the general formula V carries -OH and/or -SH and/or -NH₂ groups. Said radicals cause an increase of the absorption in the NIR, but after polycondensation they can be used for coupling with other components, the absorption of the resulting materials thereby being reduced again. With the help of the aforementioned radicals, the resulting polycondensates can be provided with further functionalities. In this way, a chemical modification of the polycondensates according to the invention is possible.

Thus, e. g. triacrylates can be added by performing a Michael condensation onto a -CH₂-SH group, thereby forming a thioether group. Further examples of a chemical modification are the formation of urethane and urea derivatives, respectively, by addition of isocyanate compounds onto -CH₂-OH and -CH₂-NH₂ groups, respectively, of the polycondensates.

Up to 90 mole percent of the compounds of the general formula II can be replaced by one or more compounds of the general formula III and/or IV and/or V. In preferred embodiments of the silicic acid polycondensates according to the invention, not more than 80 mole percent of the compounds of the general formula II are replaced by compounds of the general formula III and/or IV and/or V.

Further embodiments of the silicic acid polycondensates according to the invention are obtainable by adding organically modified silicic acid polycondensates according to the invention as a resin and/or particles to the reaction medium prior to and/or during and/or after condensation. The advantage is that different properties of different resin or resin particle systems can be combined. In this way, the properties of the resulting polycondensates, such as for example the refractive index, thermal expansion coefficient or polymerization shrinkage, can be adapted to the requirements of the particular application case.

The production of the silicic acid polycondensates according to the invention is effected in a single-stage, anhydrous process. In the synthetic scheme, no water is used as an educt. Thereby, an unambiguous reaction sequence is enforced and secondary reactions are suppressed. Due to the presence of a base and an increased reaction temperature, e. g. at 50°C, a short reaction period and an almost stoichiometric conversion of the educts is obtained.

When condensing two or more compounds of the general formula I and/or II with each other, all educts are homogeneously condensed into the silicic acid polycondensate according to the invention by the reaction scheme according to the invention. Said homogeneous condensation allows to selectively and gradually adjust (index tuning) the refractive index of the resulting silicic acid polycondensates.

The silicic acid polycondensate/alcohol mixture obtained is concentrated at an increased temperature until complete removal of the volatile components. The completeness of the reaction can be controlled by the decrease in weight according to the stoichiometric equation. The total mass of the batch will decrease exactly by a

previously calculated mass of volatile components. The analysis of the volatile components removed will confirm the assumptions concerning the stoichiometry of the conversion.

5 The silicic acid polycondensates according to the invention can be used either as such or in compositions additionally containing additives which are adapted to the intended application, e. g. usual paint additives, fillers, photoinitiators, thermal initiators, flow-control agents and pigments.

10 Surprisingly it was found that the polycondensates according to the invention are particularly stable in storage. Even when being stored for a prolonged term at room temperature (observed over a period of 1 year), they do not gel. Epoxy resins known from prior art only show low stability in storage. Already after a short term, the number of epoxy groups will decrease and the viscosity of said resins will increase. Surprisingly it was found that even inventive polycondensates having epoxy groups show excellent stability in storage as described above. Therefore, the polycondensates according to the invention provide epoxy resins having an excellent stability in storage.

15
20
25 The silicic acid polycondensates according to the invention do not have any or have only a small number of SiOH groups. They are UV curable and NIR permeable, particularly the permeability at wave lengths of 1310 nm and 1550 nm being important for technical applications in optical data processing. Effecting curing, i. e. polymerization of the C=C double bonds and of the epoxy groups, respectively, is accompanied by a sufficiently low shrinkage. Thereby, the formation of cracks is avoided even for layers having a high thickness. It is assumed that the absence of Si-OH groups and of volatile components in the silicic acid polycondensates according to the invention is responsible for this effect. Moreover, the silicic acid polycondensates according to the invention are photostructurable in layers having a thickness of up to 150 μm without loss in quality. These properties render the silicic acid polycondensates according to the invention
30 extraordinarily suitable for use as photoresists, as a negative resist, as a dielectric, as light transmitting transparent material or as photostructurable insulating material for micro systems technology. Just in this technology photostructurable materials are needed which require a high reproducibility of the material properties, such as viscosity, solubility, water content, etc. The silicic acid polycondensates according to the invention
35 are very well suited for these applications. They present a very good reproducibility of all material properties, such as e. g. the refractive index (± 0.001), the optical attenuation and the working properties in all process steps of UV structuring.

The silicic acid polycondensates according to the invention are inorganically reacted to completeness and show a reduced release of volatile components, such as water or alcohol, during the thermal curing process and therefore, they are well embossable.

The use of the silicic acid polycondensates according to the invention is not limited to the aforementioned applications. Wherever organically modified silicic acid polycondensates can be used as scratch-resistant coatings for a very wide range of substrates, as adhesive and sealing compounds or for the production of moldings, it is possible to make use of the silicic acid polycondensates according to the invention due to their excellent material properties. The silicic acid polycondensates according to the invention excellently adhere to a very wide range of substrates, such as for example to metals, to glass or to oxidic surfaces. As far as metals are concerned, particularly the adhesion to aluminum and to silicon is to be mentioned.

Therefore, the inventive silicic acid polycondensates or compositions containing same are excellently suited for the production of coating, filler or bulk materials, of adhesives and injection molding materials, of fibers, foils or films, adhesion agents, of impression materials and of embedding compounds. Particular fields of application are e. g. the coating of substrates made of metal, plastic, paper, ceramics, etc. by dipping or immersion, casting, painting, spray-painting, electrostatic sputtering, electro-dipcoating, etc., the use for optical, optoelectrical or electronic components, the production of fillers, abrasion-resistant anticorrosion coatings, the production of moldings, e. g. by injection molding, casting or extrusion, and the production of composites, e. g. comprising fibers, fillers or woven fabrics.

After polycondensation and prior to further processing, solvents can be added to the polycondensate for dilution. The final curing of the inventive silicic acid polycondensates is effected by thermal or photochemical methods, if necessary after adding suitable initiators, wherein said curing mechanisms can also proceed in parallel and/or subsequently. During polymerization or polyaddition, the C=C double bonds or the epoxy groups, respectively, are linked together, and the organic network is formed. Due to the relatively high molecular weights of the polycondensates according to the invention, their volume shrinkage during curing is only small.

It is also possible to add further ionically and/or radically polymerizable components to the inventive polycondensate prior to final curing, thus e. g. prior to polymerization. Radically polymerizable compounds that can be added are e. g. compounds having C=C double bonds, such as acrylates or methacrylates, wherein polymerization occurs

via said C=C double bonds. Ionically polymerizable compounds that can be added may contain e. g. cyclic systems that are polymerizable by a cationic ring-opening polymerization, such as spiroorthoesters, spiroortho carbonates, bicyclic spiroorthoesters, mono or oligoepoxides or spirosilanes. Further, compounds can be added that are both ionically and radically polymerizable, as e. g. methacryloyl spiroorthoesters. Polymerization of these compounds can be effected radically via the C=C double bond or cationically by ring-opening. Said systems are e. g. described in Journal f. prakt. Chemie, vol. 330, issue 2, 1988, p. 316-318, or in Journal of Polymer Science: Part C: Polymer Letters, vol. 26, p. 517-520 (1988).

When the polycondensates according to the invention are cured by photochemical methods, photoinitiators are added thereto, and when they are cured by thermal hardening methods, thermal initiations are added. The initiator may be added in usual quantities. Thus, e. g. to a mixture containing 30 to 50 weight-% of solid substance (polycondensate), initiators can be added in a quantity of e. g. 0.5 to 5 weight-%, particularly 1 to 3 weight-%, in relation to the mixture.

Commercially available photoinitiators can e. g. be used. Examples are Irgacure 184 (1-hydroxy cyclohexyl phenyl ketone), Irgacure 500 (1-hydroxy cyclohexyl phenyl ketone/benzophenone) and other photoinitiators of the Irgacure type which are available from Ciba-Geigy; Darocure 1173, 1116, 1398, 1174 and 1020 (available from Merck), benzophenone, 2-chlorothioxanthone, 2-methylthioxanthone, 2-isopropylthioxanthone, benzoin, 4,4'-dimethoxybenzoin, etc. When curing is effected by visible light, camphorquinone may for example be used as an initiator.

As thermal initiators, particularly organic peroxides are suited, for example diacyl peroxides, peroxydicarbonates, alkyl per-esters, dialkyl peroxides, perketalene, ketone peroxides and alkyl hydroperoxides. Concrete and preferred examples of thermal initiators are dibenzoyl peroxide, t-butyl perbenzoate and azobisisobutyronitrile.

When diluting the silicic acid polycondensates according to the invention by a solvent, said solvent is preferably allowed to dry off prior to curing. Thereafter, it can be cured thermally or photochemically as know per se, depending on the type of initiator. Combinations of hardening methods are of course also possible.

When curing of the inventive silicic acid polycondensates is effected by radiation, it can be advantageous to effect a thermal curing step subsequently to the radiation curing,

particularly for removing solvent that is still present or for introducing further reactive groups into the curing process.

The polycondensates according to the invention are structured photochemically, if necessary by adding usual initiators. Suitable initiators are e. g. the Irgacure[®] products of CIBA or the Cyracure[®] products of Union Carbide. Both polycondensates having C=C double bonds (radically initiated) and polycondensates having epoxy groups (ionically induced) can be photochemically structured.

The silicic acid polycondensates are described in more detail by way of specific examples.

Example 1:

<u>Educts</u>	(1) diphenylsilanediol	1 mole
	(2) 3-methacryloxypropyl trimethoxysilane	1 mole
	(3) barium hydroxide monohydrate	0.4 g (0.002 mole)

Synthesis

Component (1) is provided. Then (2) and finally (3) are added. The mixture is heated to 80°C and vigorously stirred under reflux. After 4 minutes, a clear solution is formed, after 15 minutes, the reaction is completed. The resulting solution is concentrated at 80°C under reduced pressure, at first 40 minutes at 670 mbar. Next, pressure is slowly reduced to 400 mbar within 20 minutes and subsequently gradually to 6 mbar and is maintained at said value for one hour. Subsequently, at a pressure of 6 mbar, temperature is increased to 90°C for one hour, for completely removing the methanol formed during the reaction. Thereafter, the resulting resin is pressure-filtered at 0.2 µm.

Optical properties of the resulting resin

The resulting resin does not show Si-OH groups in the infrared spectrum.

Refractive index at 25°C = 1.5382.

Optical attenuation in the NIR = 0.30 dB/cm at 1310 nm

= 0.65 dB/cm at 1550 nm.

Reproduction of the experiment

<u>Educts</u>	(1) diphenylsilanediol	1 mole
	(2) 3-methacryloxypropyl trimethoxysilane	1 mole
	(3) barium hydroxide monohydrate	0.4 g (0.002 mole)

Synthesis is effected as described above.

Optical properties of the resulting resin

The resulting resin does not show Si-OH groups in the infrared spectrum.

Refractive index at 25°C = 1.5382.
Optical attenuation in the NIR = 0.30 dB/cm at 1310 nm
= 0.65 dB/cm at 1550 nm.

The viscosity of said two resins and that of four additional resins (according to the same synthetic scheme) is $5.2 \pm 0.4 \text{ Pa}\cdot\text{s}$.

Example 2:

<u>Educts</u>	(1) diphenylsilanediol	95.18g (0.44 mole)
	(2) 3.3.3-trifluoropropyl trimethoxysilane	48.02 g (0.22 mole)
	(3) 3-methacryloxypropyl trimethoxysilane	54.64 g (0.22 mole)
	(4) barium hydroxide monohydrate	0.15 g (0.0008 mole)

Synthesis

Component (1) is provided. Then (3) and (2) and finally (4) are added. The mixture is heated to 80°C and vigorously stirred under reflux. After 4 minutes, a clear solution is formed, after 15 minutes, the reaction is completed. The resulting solution is concentrated at 80°C under reduced pressure, at first 40 minutes at 670 mbar. Then, pressure is slowly reduced to 400 mbar within 20 minutes and subsequently gradually to 6 mbar and is maintained at said value for one hour. Subsequently, at a pressure of 6 mbar, temperature is increased to 90°C for one hour, for completely removing the methanol formed during the reaction.

Optical properties of the resulting resin:

The resulting resin does not show Si-OH groups in the infrared spectrum.

Refractive index at 25°C = 1.5243.
Optical attenuation in the NIR = 0.27 dB/cm at 1310 nm
= 0.50 dB/cm at 1550 nm.

Reproduction of the experiment

The reproduction of the synthesis provides a resin having an identical infrared spectrum and a refractive index of 1.5245 at 25°C. The optical attenuation values of the resin in the NIR are identical with those mentioned above within the scope of measuring accuracy.

Further, the following resins were produced according to the synthetic scheme described in examples 1 and 2.

Example 3:

<u>Educts</u>	(1) diphenylsilanediol	21.26 g (0.1 mole)
	(2) 3-methacryloxypropyl trimethoxysilane	19.87 g (0.08 mole)
	(3) 3-aminopropyl trimethoxysilane	3.58 g (0.02 mole)

The condensation is catalyzed by the 3-aminopropyl group of component (3).

Example 4:

<u>Educts</u>	(1) diphenylsilanediol	21.63 g (0.1 mole)
	(2) 3-methacryloxypropyl trimethoxysilane	20.68 g (0.084 mole)
	(3) Zr(OPr) ₄	2.62 g (0.008 mole)

The condensation is catalyzed by component (3).

Example 5:

<u>Educts</u>	(1) diphenylsilanediol	95.18 g (0.44 mole)
	(2) 3,3,3-trifluoropropyl trimethoxysilane	48.02 g (0.22 mole)
	(3) 3-methacryloxypropyl trimethoxysilane	54.64 g (0.22 mole)
	(4) barium hydroxide monohydrate	0.15 g (0.0008 mole)

Example 6:

<u>Educts</u>	(1) diphenylsilanediol	21.63 g (0.100 mole)
	(2) 3-methacryloxypropyl trimethoxysilane	15.90 g (0.064 mole)
	(3) Al(O-s-Bu) ₃	5.91 g (0.024 mole)

The condensation is catalyzed by component (3).

Example 7:

<u>Educts</u>	(1) diphenylsilanediol	1.77 g (0.008 mole)
	(2) tridecafluoro-1.1.2.2-tetra-hydrooctyl-triethoxysilane	4.21 g (0.008 mole)
	(3) triethylamine	3 drops

The condensation is catalyzed by component (3).

Example 8:

<u>Educts</u>	(1) diphenylsilanediol	108.18 g (0.5 mole)
	(2) 2-(3,4-epoxycyclohexyl)ethyl trimethoxysilane	123.19 g (0.5 mole)
	(3) barium hydroxide monohydrate	0.2 g (0.001 mole)

The theoretical epoxid content of the resin, the real content immediately after production, after 30 days and after one year is 2.4 mmole/g, respectively.

Example 9:

<u>Educts</u>	(1) diphenylsilanediol	108.18g (0.5 mole)
	(2) 3-methacryloxypropyl trimethoxysilane	62.09 g (0.25 mole)
	(3) 2-(3.4-epoxycyclohexyl)ethyl trimethoxysilane	61.6 g (0.25 mole)
	(4) barium hydroxide monohydrate	0.2 g (0.001 mole)

Example 10:

<u>Educts</u>	(1) diphenylsilanediol	21.63 g (0.1 mole)
	(2) 2-(3.4-epoxycyclohexyl)ethyl trimethoxysilane	12.32 g (0.05 mole)
	(3) vinyltrimethoxysilane	7.41 g (0.05 mole)
	(4) barium hydroxide monohydrate	0.038 g (0.0002 mole)

Example 11:

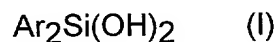
<u>Educts</u>	(1) diphenylsilanediol	108.18g (0.5 mole)
	(2) 2-(3.4-epoxycyclohexyl)ethyl trimethoxysilane	123.19 g (0.5 mole)
	(3) ammonium fluoride	0.05 g (0.0013 mole)

The water content of all resins according to examples 1 to 11 is less than 0.01 % (= 100 ppm) and is determined by a Karl Fischer titration. All resins described are UV structurable, thermally curable without crack formation at temperatures markedly above 200°C and applicable in several layers one upon the other. The thermally cured layers do not show modifications after climate investigations during 7 days.

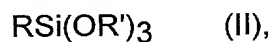
* * *

Claims:

1. Organically modified, stable in storage, UV curable, NIR permeable silicic acid polycondensate which is photostructurable in layers having a thickness of 1 to 150 μm , **obtainable** by condensation of one or more organically modified silanediols of the general formula I and/or precondensates derived therefrom



with one or more organically modified silanes of the general formula II



wherein condensation occurs without the addition of water,

wherein the molar ratio of the compounds I and II in relation to the monomers is 1 : 1,

wherein up to 90 mole percent of said compound II can be replaced by one or more co-condensable compounds of boron, aluminum, silicon, germanium, titanium and zirconium,

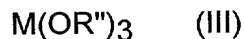
and wherein the radicals are identical or different and have the following meaning:

Ar = a radical having 6 to 20 carbon atoms and at least one aromatic group,

R = an organic radical having 2 to 15 carbon atoms and at least one epoxy group and/or at least one C=C double bond,

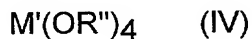
R' = methyl or ethyl.

2. Silicic acid polycondensate according to claim 1, **characterized in that** up to 90 mole percent of said compound of the general formula II are replaced by one or more compounds of the general formula III,



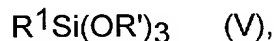
in which M means one of boron and aluminum, R'' represents an alkyl radical with 1 to 4 carbon atoms, and wherein the molar ratio of said replaced compound II in relation to said compound III is 3 : 2.

3. Silicic acid polycondensate according to one of claims 1 and 2, **characterized in that** up to 90 mole percent of said compound of the general formula II are replaced by one or more compounds of the general formula IV



in which M' means silicon, germanium, titanium or zirconium, R'' represents an alkyl radical having 1 to 4 carbon atoms, and wherein the molar ratio of said replaced compound II in relation to said compound IV is 2 : 1.

4. Silicic acid polycondensate according to one or more of claims 1 to 3, **characterized in that** up to 90 mole percent of said compound of the general formula II are replaced by one or more compounds of the general formula V, wherein the molar ratio of said replaced compound II in relation to compound V is 1 : 1,



and wherein the radicals are identical or different and have the following meaning:

R' = methyl or ethyl,

R¹ = CF₃-(CF₂)_n-C₂H₄-, with n = 0 to 7,

R²HN-(CH₂)₃-, with R² = H, CH₃, C₂H₅ or C₂H₄-NHR²,

H₂N-C₂H₄-NH-CH₂-C₆H₄-C₂H₄-,

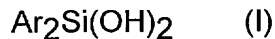
substituted and unsubstituted alkyl having 1 to 8 carbon atoms,

substituted and unsubstituted phenyl, tolyl and naphthyl.

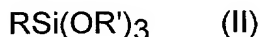
5. Silicic acid polycondensate according to one or more of claims 1 to 4, **characterized in that** up to 80 mole percent of said compound II are replaced by one or more compounds of the general formula III and/or IV and/or V.
6. Silicic acid polycondensate according to one or more of claims 1 to 5, **obtainable by** using a condensation catalyst which is triethylamine, NH₄F or an alkaline earth hydroxide.
7. Silicic acid polycondensate according to one or more of claims 1 to 6, **obtainable by** compounds of the general formula III, IV (with M' being Ti or Zr) or V (with R¹ being R²HN-(CH₂)₃- or H₂N-C₂H₄-NH₂-CH₂-C₆H₄-C₂H₄-) acting as condensation catalysts.

8. Silicic acid polycondensate according to one or more of claims 1 to 7,
characterized in that said radical Ar of the general formula I means a substituted aromatic radical.
9. Silicic acid polycondensate according to claim 8, **characterized in that** said radical Ar of the general formula I means phenyl, naphthyl or styryl.
10. Silicic acid polycondensate according to one or more of claims 1 to 9,
characterized in that said radical R of the general formula II contains functional groups.
11. Silicic acid polycondensate according to one or more of claims 1 to 10,
characterized in that said radical R¹ of the general formula V contains SH groups and/or NR^{*}₂ groups, with R^{*} being hydrogen or alkyl.
12. Silicic acid polycondensate according to one or more of claims 1 to 11,
characterized in that said radical R of the general formula II contains at least one acryl and/or methacryl group.
13. Silicic acid polycondensate according to one or more of claims 1 to 12, **obtainable by** adding polysiloxanes to the reaction medium, said polysiloxanes having been obtained by reacting organically modified silanediols of the general formula I with organically modified silanes of the general formula II.
14. Use of the organically modified silicic acid polycondensates according to one or more of claims 1 to 13 as stable in storage, UV curable, NIR permeable materials which are photostructurable in layers of a thickness of 1 to 150 µm.
15. Use according to claim 14 as a negative resist.

16. Method for producing the silicic acid polycondensates according to claim 1 by condensing one or more organically modified silanediols of the general formula I and/or precondensates derived therefrom



with one or more organically modified silanes of the general formula II



in the presence of a base,

wherein condensation occurs without the addition of water,

wherein the molar ratio of the compounds I and II in relation to the monomers is 1 : 1,

wherein up to 90 mole percent of said compound II can be replaced by one or more co-condensable compounds of boron, aluminum, silicon, germanium, titanium and zirconium,

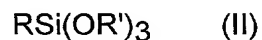
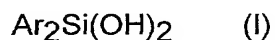
and wherein the radicals are identical or different and have the following meaning:

- Ar = a radical having 6 to 20 carbon atoms and at least one aromatic group,
R = an organic radical having 2 to 15 carbon atoms and at least one epoxy group and/or at least one C=C double bond,
R' = methyl or ethyl.

* * *

Abstract

The invention relates to organically modified, stable in storage, UV curable, NIR permeable silicic acid polycondensates which are photostructurable in layers having a thickness of 1 to 150 μm . The invention also relates to the production and use thereof as negative resists. The polycondensates according to the invention are obtainable by condensation of organically modified silanediols of the formula I with organically modified silanes of the formula II.



The radicals are identical or different and have the following meaning:

Ar = a radical having 6 to 20 carbon atoms and at least one aromatic group,

R = an organic radical having 2 to 15 carbon atoms and at least one epoxy group and/or at least one C=C double bond,

R' = methyl or ethyl.

Condensation occurs without the addition of water. The molar ratio of said compounds I and II is 1 : 1. Up to 90 mole percent of said compound of the formula II can be replaced by co-condensable compounds of boron, aluminum, silicon, germanium, titanium and zirconium.

* * *

DECLARATION AND POWER OF ATTORNEY

As a below named inventor, I HEREBY DECLARE:

THAT my residence, post office address, and citizenship are as stated below next to my name;

THAT I believe I am the original, first, and sole inventor (if only one inventor is named below) or an original, first, and joint inventor (if plural inventors are named below or in an attached Declaration) of the subject matter which is claimed and for which a patent is sought on the invention entitled

**ORGANICALLY MODIFIED SILIC ACID POLYCONDENSATES, PRODUCTION AND USE
THEREOF**

(Attorney Docket No. 060953-0131)

the specification of which (check one)

 is attached hereto.

 X was filed on as United States Application Number or PCT
International Application Number PCT/DE00/01833 and was
amended on (if applicable).

THAT I do not know and do not believe that the same invention was ever known or used by others in the United States of America, or was patented or described in any printed publication in any country, before I (we) invented it;

THAT I do not know and do not believe that the same invention was patented or described in any printed publication in any country, or in public use or on sale in the United States of America, for more than one year prior to the filing date of this United States application;

THAT I do not know and do not believe that the same invention was first patented or made the subject of an inventor's certificate that issued in any country foreign to the United States of America before the filing date of this United States application if the foreign application was filed by me (us), or by my (our) legal representatives or assigns, more than twelve months (six months for design patents) prior to the filing date of this United States application;

THAT I have reviewed and understand the contents of the above-identified specification, including the claim(s), as amended by any amendment specifically referred to above;

THAT I believe that the above-identified specification contains a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the invention, and sets forth the best mode contemplated by me of carrying out the invention; and

THAT I acknowledge the duty to disclose to the U.S. Patent and Trademark Office all information known to me to be material to patentability as defined in Title 37, Code of Federal Regulations, §1.56.

I HEREBY CLAIM foreign priority benefits under Title 35, United States Code § 119(a)-(d) or § 365(b) of any foreign application(s) for patent or inventor's certificate, or § 365(a) of any PCT international application which designated at least one country other than the United States of America, listed below and have also identified below any foreign application for patent or inventor's certificate or of any PCT international application having a filing date before that of the application on which priority is claimed.

Prior Foreign Application Number	Country	Foreign Filing Date	Priority Claimed?	Certified Copy Attached?
DE 199 32 629.0	Germany	07/13/1999	YES	

I HEREBY CLAIM the benefit under Title 35, United States Code § 119(e) of any United States provisional application(s) listed below.

U.S. Provisional Application Number	Filing Date

I HEREBY CLAIM the benefit under Title 35, United States Code, § 120 of any United States application(s), or § 365(c) of any PCT international application designating the United States of America, listed below and, insofar as the subject matter of each of the claims of this application is not disclosed in the prior United States or PCT International application in the manner provided by the first paragraph of Title 35, United States Code, § 112, I acknowledge the duty to disclose information which is material to patentability as defined in Title 37, Code of Federal Regulations, § 1.56 which became available between the filing date of the prior application and the national or PCT international filing date of this application.

U.S. Parent Application Number	PCT Parent Application Number	Parent Filing Date	Parent Patent Number
	PCT/DE00/01833	05/31/00	

I HEREBY APPOINT the following registered attorneys and agents of the law firm of FOLEY & LARDNER:

STEPHEN A. BENT	Reg. No. <u>29,768</u>
DAVID A. BLUMENTHAL	Reg. No. <u>26,257</u>
BETH A. BURROUS	Reg. No. <u>35,087</u>
ALAN I. CANTOR	Reg. No. <u>28,163</u>
WILLIAM T. ELLIS	Reg. No. <u>26,874</u>
JOHN J. FELDHAUS	Reg. No. <u>28,822</u>
MICHAEL D. KAMINSKI	Reg. No. <u>32,904</u>
LYLE K. KIMMS	Reg. No. <u>34,079</u>
KENNETH E. KROSIN	Reg. No. <u>25,735</u>

JOHNNY A. KUMAR	Reg. No. 34,649
JACK LAHR	Reg. No. 19,621
GLENN LAW	Reg. No. 34,371
PETER G. MACK	Reg. No. 26,001
STEPHEN B. MAEBIUS	Reg. No. 35,264
BRIAN J. MC NAMARA	Reg. No. 32,789
RICHARD C. PEET	Reg. No. 35,792
GEORGE E. QUILLIN	Reg. No. 32,792
ANDREW E. RAWLINS	Reg. No. 34,702
BERNHARD D. SAXE	Reg. No. 28,665
CHARLES F. SCHILL	Reg. No. 27,590
RICHARD L. SCHWAAB	Reg. No. 25,479
MICHELE M. SIMKIN	Reg. No. 34,717
HAROLD C. WEGNER	Reg. No. 25,258

to have full power to prosecute this application and any continuations, divisions, reissues, and reexaminations thereof, to receive the patent, and to transact all business in the United States Patent and Trademark Office connected therewith.

I request that all correspondence be directed to:

Stephen A. Bent
FOLEY & LARDNER
Washington Harbour
3000 K Street, N.W., Suite 500
Washington, D.C. 20007-5143

Telephone: (202) 672-5404
 Facsimile: (202) 672-5399

I UNDERSTAND AND AGREE THAT the foregoing attorneys and agents appointed by me to prosecute this application do not personally represent me or my legal interests, but instead represent the interests of the legal owner(s) of the invention described in this application.

I FURTHER DECLARE THAT all statements made herein of my own knowledge are true, and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code, and that such willful false statements may jeopardize the validity of the application or any patent issuing thereon.

Name of first inventor	<u>Christof ROSCHER</u>
Residence	<u>Wuerzburg, Germany</u> <i>DEX</i>
Citizenship	<u>Germany</u>
Post Office Address	<u>Wagnerstrasse 15</u> <u>D-97080 Wuerzburg</u> <u>Germany</u>
Inventor's signature	<u><i>(Signature)</i></u>
Date	<u><i>21.1.02.</i></u>

Name of second inventor

Ralf BUESTRICH

Residence

Wuerzburg, Germany

DEX

Citizenship

Germany

Post Office Address

Innerer Graben 31-33

D-97080 Wuerzburg

Germany

Inventor's signature

Ralf Buestrich

Date

04/15/02

200250 060953-0131